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N THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant:

Guogiang Xing, et al.

Serial No:

09/901,416

Examiner:

Thanh T. Nguyen

Filed:

07/09/2001

For:

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INTERCONNECTS

INFORMATION DISCLOSURE STATEMENT UNDER 37 CFR 1.56

Commissioner For Patents P.O. Box 1450 Alexandria, VA 22313-1450 MAILING CERTIFICATE UNDER 37 C.F.R. § 1.8(a)
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Art Unit:

Ann Trent

Dear Sir:

In the matter of the above identified application, Applicants are submitting herewith copies of the documents listed in the attached form PTO/SB/08A that were cited in a communication from a foreign patent office in a counterpart foreign application.

It is respectfully submitted that this Information Disclosure Statement be considered by the Examiner.

Please charge any shortage in the fees due in connection with the filing of this paper, including extension of time fees, to the deposit account of Texas Instruments

Incorporated, Account No. 20-0668, and please credit any excess fees to such Deposit Account.

Respectfully submitted,

Peter K. McLarty

Attorney for Applicants

Reg. No. 44,923

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Substitute for Form 1449A/PTO	Application Number	09/901,416			
AUG 0 1 2003 7 NFORMATION DISCLOSURE	Filing Date	07/09/2001			
SISTATEMENT BY ADDITIONT	First Named Inventor	Guoqiang Xing, et al.			
	Group Art Unit	2813			
(use as many sheets as necessary)	Examiner Name	Thanh T. Nguyen			
1 of	1	Attorney Docket No.	TI-31729		

				U.:	S. PATENT DOCU	MENTS
Exam. Initials*	Cite No.1	U.S. Patent Document		Name of Patentee	Date of Pub.	
		Number	Kind Code ² (if known)	or Applicant of Cited Doc.	of Cited Doc. (mm-dd-yyyy)	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear
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Examiner	Date	
Signature	Considered	
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¹Unique citation designation number. ²Applicant is to place a check mark here if English Translation is attached.